

12

EUROPEAN PATENT APPLICATION

21 Application number: 89203034.7

51 Int. Cl.⁵ H01J 29/07

22 Date of filing: 29.11.89

30 Priority: 05.12.88 US 279889

43 Date of publication of application:
13.06.90 Bulletin 90/24

64 Designated Contracting States:
DE FR GB IT NL

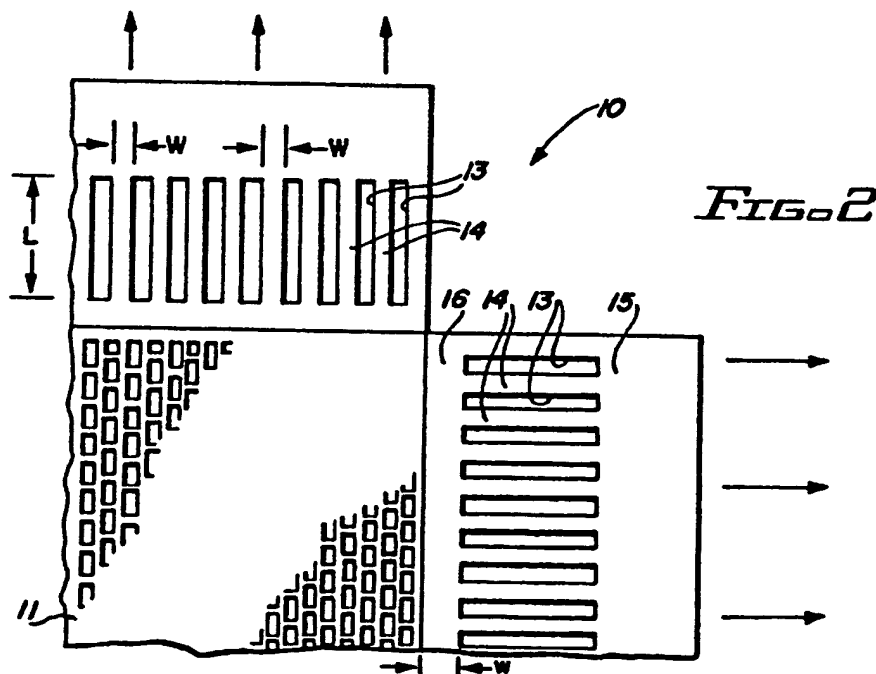
71 Applicant: N.V. Philips' Gloeilampenfabrieken
Groenewoudseweg 1
NL-5621 BA Eindhoven(NL)

72 Inventor: Knox, Lawrence
c/o INT. OCTROOIBUREAU B.V. Prof.
Holstlaan 6
NL-5656 AA Eindhoven(NL)

74 Representative: Koppen, Jan et al
INTERNATIONAAL OCTROOIBUREAU B.V.
Prof. Holstlaan 6
NL-5656 AA Eindhoven(NL)

54 Shadow mask with border pattern.

57 A rectangular shadow mask is characterized by having a pattern of slits in the border regions of the mask in order to provide uniform distribution of tensile stresses across the mask when mounted in the CRT, resulting in improved mechanical and thermal behavior, and enabling the separate fabrication of the mask and display screen of the CRT.



EP 0 372 630 A2

Shadow mask with border patternBackground of the invention

This invention relates to a shadow mask for a flat face cathode ray tube (CRT) for color display, and more particularly relates to such a mask having a border pattern.

5 Cathode ray tubes for colour television and allied display applications typically employ a shadow mask to shadow (spatially filter) the electron beams coming from the three electron guns mounted in the neck of the tube, such that each beam excites only one color of a three-color phosphor display screen disposed on the internal surface of the face of the tube. This shadowing is accomplished by providing an array of apertures in the mask corresponding to an array of phosphor elements in the screen.

10 Conventional CRT faces are curved. Currently, two-dimensional (cylindrical) or three-dimensional (quasi-spherical) curvatures are employed. Although CRTs have recently been developed which have faces with reduced curvatures, it would be desirable for a number of reasons, including aesthetic appearance, reduced ambient light reflections and fabrication costs, to have a CRT with a face with no curvature at all.

15 A flat-faced CRT is currently being developed in which the shadow mask is tensioned behind the flat display surface, much like a drum skin, to provide structural rigidity and to overcome thermal distortion problems during operation. A uniform stress distribution in this mask is desirable since this allows the use of higher tensioning stresses which further improves the structural and thermal behavior. Such tensioning stresses could be as high as 60 to 80 % of the yield stress of the mask material.

20 Additional advantages in tube design and cost of automation could be realized if a "non-married" fabrication process could be used, that is, the shadow mask and phosphor patterns are produced independently, rather than dependently as is the present practice for conventional color CRTs. To achieve such a "non-married" fabrication process, the accuracy of aperture and phosphor element placement within 5 to 10 microns must be uniformly achievable.

25

Object and Summary of the Invention

It is an object of the invention to provide a border pattern surrounding the apertured (viewing) area of a tensioned shadow mask, which border pattern provides a uniform stress distribution in the viewing area of the mask when the edges of the mask are subjected to either a uniform displacement or a uniform edge loading.

30 In accordance with the invention, a border pattern is provided on a rectangular shadow mask for tensioned mounting on a flat faced colour CRT. The border of the mask comprising strips of material surrounding the central, apertures (viewing) area of the mask. In each strip, slits which are mutually parallel to one another and orthogonal to the adjacent edge of the apertures area, form legs, also orthogonal to the edge of the apertured area. These legs connect the apertured area to outer regions of the border strips used to secure the mask to the CRT.

35 The length of and spacing between the slits are chosen to provide a border which is relatively stiff in tension, but relatively flexible in transverse bending. The ratio of the length L to the spacing W between adjacent edges of the slits, referred to herein as the aspect ratio, varies as the square of the ratio of the tensile stiffness to the bending stiffness.

40 In addition, the transverse bending should be small relative to the length L to assure that the tensile forces are substantially orthogonal to the adjacent edge of the apertured area.

45

Brief Description of the Drawings.

Fig. 1 is a schematic diagram of a shadow mask for a flat faced colour cathode ray tube of the invention, including a border region having a pattern of slits,

50 Fig. 2 is an enlarge portion from the circled area of Fig. 1, showing in more detail the pattern of slits in the border region;

Fig. 3 is a diagrammatic representation for tensile stress analysis of a leg of border material between adjacent slits of the border pattern;

Fig. 4 is a diagram similar to that of Fig. 3 for transverse bending stress analysis;

Fig. 5 is a graphic representation of the upper right quadrant of the mask of Fig. 1;

Fig. 6 is a graphic representation of the upper right quadrant of a tensioned mask similar to that of Fig. 1, but without a border pattern, under uniform tensile stress; and

Fig. 7 is a graphic representation similar to that of Fig. 6 for a tensioned mask having a border pattern in accordance with the invention.

5

Description of the Preferred Embodiment

Referring now to Fig. 1, there is shown one embodiment of a shadow mask for a flat faced color CRT in accordance with the invention. The mask 10 comprises a rectangular central apertured or viewing region 11, and border region 12 comprising members 12a, b, c and d, each member including a pattern of mutually parallel slits 13 oriented orthogonally to the adjacent edge of the viewing area. The aperture pattern and border pattern may be produced simultaneously by selectively etching chemically a single sheath of thin metal, in accordance with known practice.

As may be better seen in Fig. 2, an enlarged portion of the mask from the circled area of Fig. 1, the slits 13 in the border elements 12 form many parallel legs 14, which connect outer solid strips 15 of the viewing area 11 via inner strips 16. Strips 15 are used to secure the mask to the tube. Due to this border pattern, the members 12 are relatively stiff when tensile forces are applied axially, that is, in the direction of the arrows shown in Fig. 2, and relatively flexible in transverse bending, that is, transverse to the direction of the arrows. Thus, the members tend to effectively transmit the tension forces required, but tend to absorb bending forces which would otherwise disturb the uniform stress distribution desired in the mask.

The width of the slits is preferably kept as small as possible. When the slits are produced by conventional chemical etching, the width is typically about 5 mils in the upper surface of the mask, which is just sufficient to allow penetration of the lower surface of the mask by the etchant.

As shown in Fig. 2, each leg 14 has a length L and a width W. The ratio of the length L to the width W, herein the aspect ratio, must be sufficiently large to achieve the desired relative stiffness in tension and flexibility in transverse bending.

Referring to Fig. 3, a stress analysis diagram of one of the legs 14 subjected to a tensile stress as indicated by the arrow, the tensile stiffness K_1 of the leg is equal to $E \times A/L$, where E is the Young's modulus of the mask material, A is equal to mask thickness t times the leg width W, and L is the leg length.

Fig. 4 is a diagram similar to that of Fig. 3 for a leg subjected to a bending force as indicated by the arrow. Bending stiffness K_2 is equal to $12 \times E \times I/L^3$, where I is equal to $t \times W^3/12$. The ratio of K_1 to K_2 is then equal to $(L/W)^2$. By way of example, where a ratio K_1/K_2 of 100 is desired, the aspect ratio L/W is 10.

An additional consideration in the design of the mask of the invention is that the transverse bending should be small relative to the length of the slit to assure that tensioning forces are substantially parallel to the mask axis intersecting the border element. The magnitude of the transverse bending is in turn determined by the size of the mask and the tensioning level of the mask.

Fig. 5 is a graphic representation of the upper right quadrant of the mask of Fig. 1, which has a height along the Y axis three-fourths of the width along the X axis. The intersection of the X and Y axes corresponds to the center of the mask. The distance from the center to point C is designated as one-half D, where D is the diagonal of the viewing area. The height and width of the viewing area quadrant can then be expressed as $3/10 D$ and $2/5 D$, respectively. The transverse bending near point A can then be expressed as $B = \sigma_h \cdot 2/5 D$

where σ_h is the average horizontal strain. The transverse bending near point B will be $B = \sigma_v \cdot 3/10 D$

where σ_v is the average vertical strain. In practice σ_h is approximately equal to σ_v , which is approximately equal to $500 \times (E - 6)$. For a mask material having a modulus of elasticity E of 30 E6 psi, and a diagonal D of 27", B is approximately equal to 0.005". For a diagonal D of 16", B is approximately equal to 0.003". As higher yield strength materials are used, the strains will increase due to increased tension loads of as much as two to five times. Depending upon the space available surrounding the viewing area of the mask, slit lengths up to 100 times the transverse bending can be accommodated.

In order to illustrate the advantages of the invention, two sets of prototype flat faced color CRTs with tensioned masks were built, one with a 27" mask diagonal and one with a 16" diagonal. Each set included a tube with a border pattern in the mask and a control tube with no border pattern in the mask. The values of L, W, and ω are as shown below:

55

	27"	16"
L	0.50"	0.25"
W	0.050"	0.025"
ω	0.050"	0.02"

5

10 In the control tubes, a pattern on the screen was observed having an edge distortion of about 100 micrometers near the edges of the viewing area. No evidence of this distortion was visible in the tubes having border patterns in accordance with the teachings of the invention.

As a further demonstration of the advantage of the invention, a finite element analysis was performed on the 27" diagonal shadow mask design, both with and without the border pattern, under uniform edge loading of 75 lbs./inch. The results are illustrated graphically in Figs. 6 and 7 in which the rows of arrows along the border indicate uniform tensile loading, and in which the areas A through E represent areas of increasing amounts of displacement of the apertures in the viewing area as a result of the tensile loading.

15 As may be seen in Fig. 6, in the mask without the border pattern the stress distribution as evidenced by the aperture displacement is non-uniform due to uneven stress levels. However, as may be seen in Fig. 7, with the border pattern, the deformation is uniform due to uniform stress levels. Such uniform stress assures the ability to predict accurately the aperture pattern after tensile loading, enabling the accurate registration of the aperture pattern with a phosphor pattern on the display screen, and thus making possible the fabrication of the screen and mask separately.

25 Claims

1. A rectangular shadow mask comprising a central apertured viewing area and a surrounding border region, the border region comprising mounting strips connected to the viewing area by a plurality of legs, the legs being mutually parallel and orthogonal to an adjacent edge of the viewing area, the border regions being relatively stiff in tension and relatively flexible in transverse bending.
2. The mask of claim 1 in which the legs are formed by a pattern of slits which are mutually parallel and orthogonal to the adjacent edge of the viewing area.
3. The mask of claim 1 in which the aspect ratio LW of the legs is at least 5.
4. The mask of claim 1 in which the aspect ratio of the legs is up to 10.
5. The mask of claim 1 in which the magnitude of the transverse bending of the border regions is small relative to the length L of the legs.
6. A flat faced color CRT including a shadow mask as claimed in one of the Claims 1 to 5 mounted in tension.

40

45

50

55

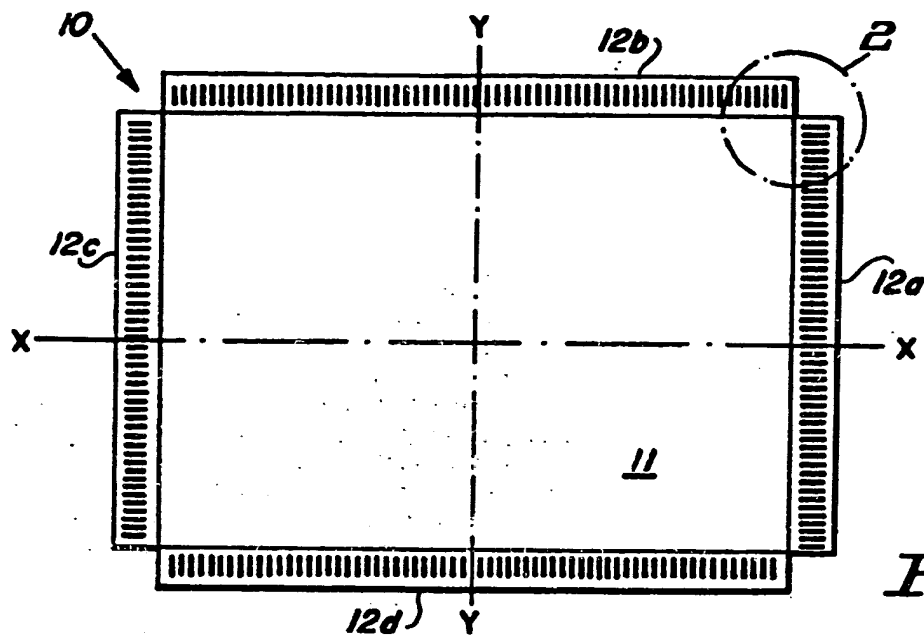


FIG. 1

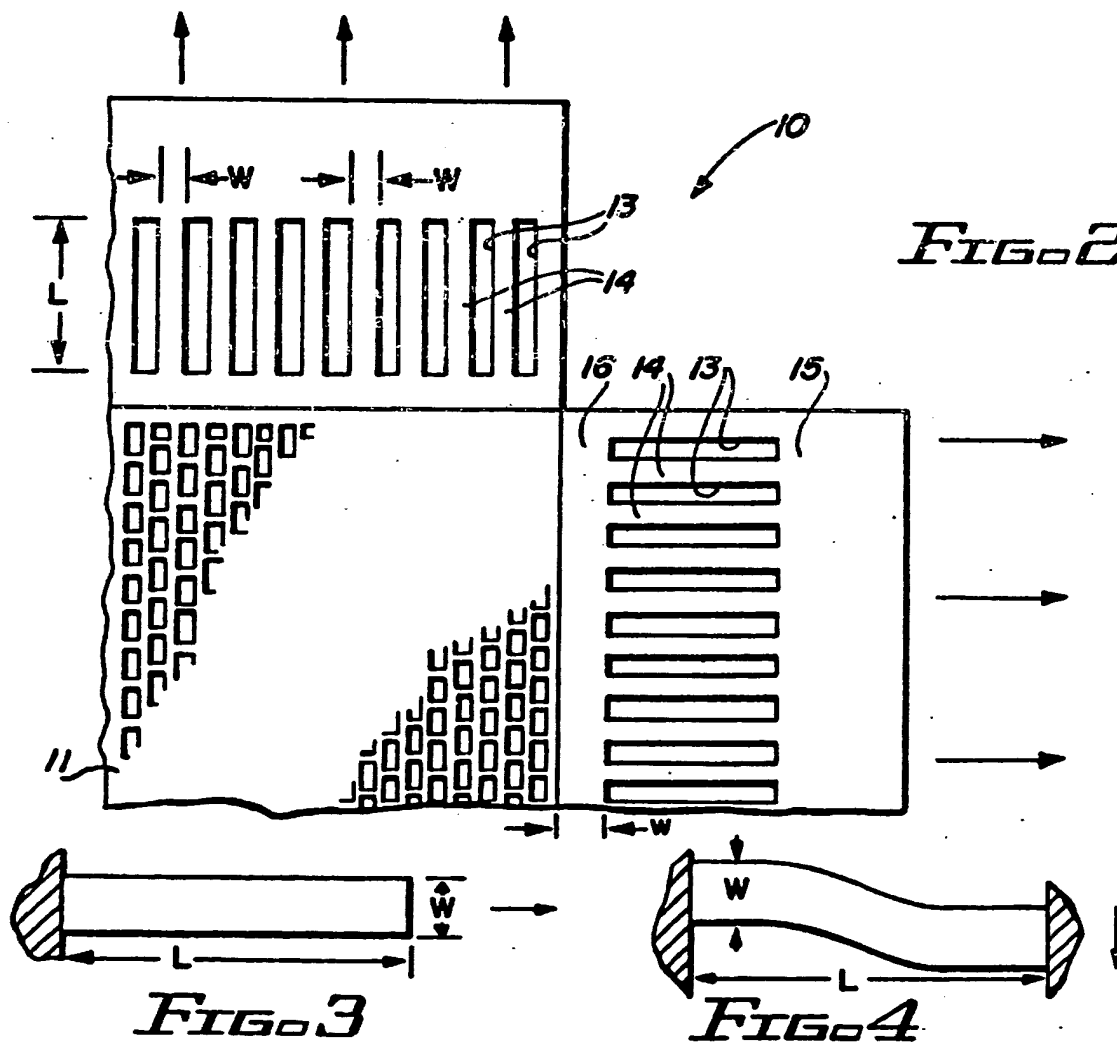


FIG. 3

FIG. 4

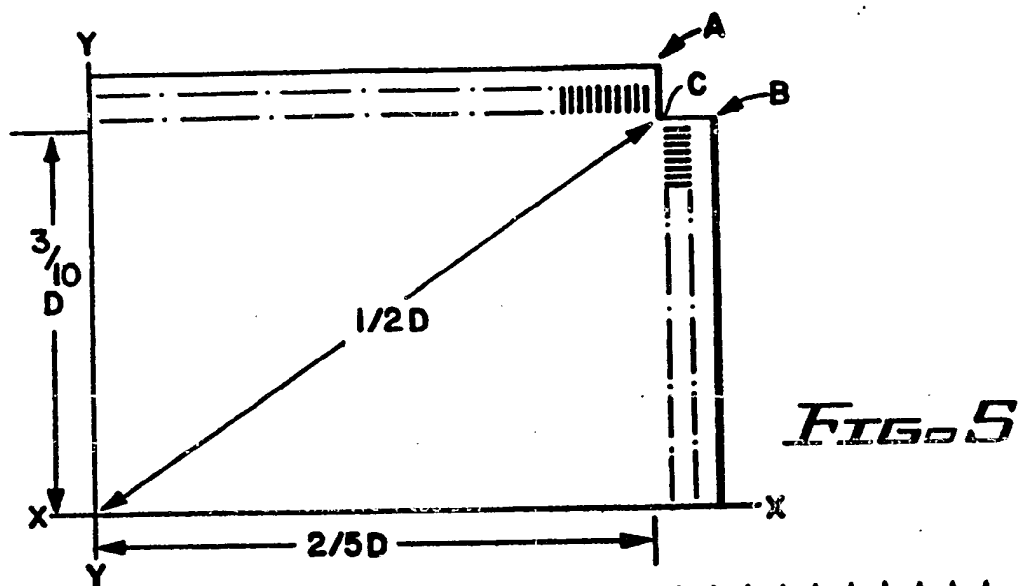


FIG. 6

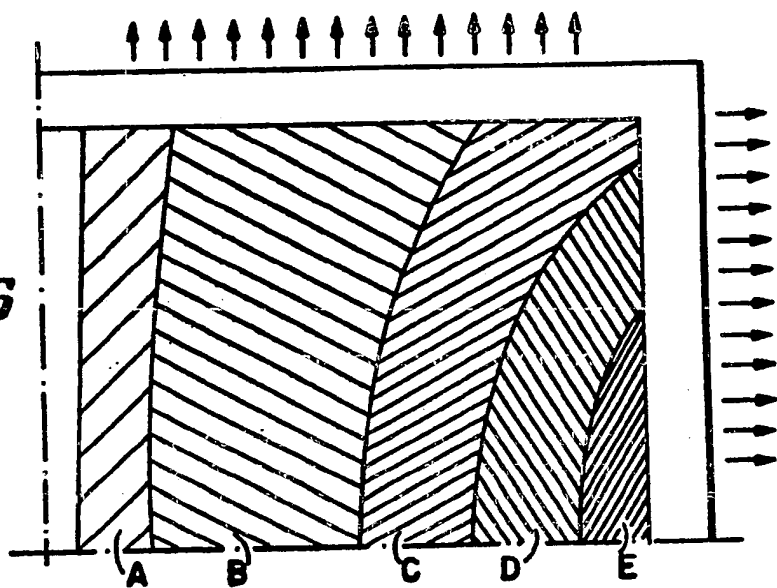
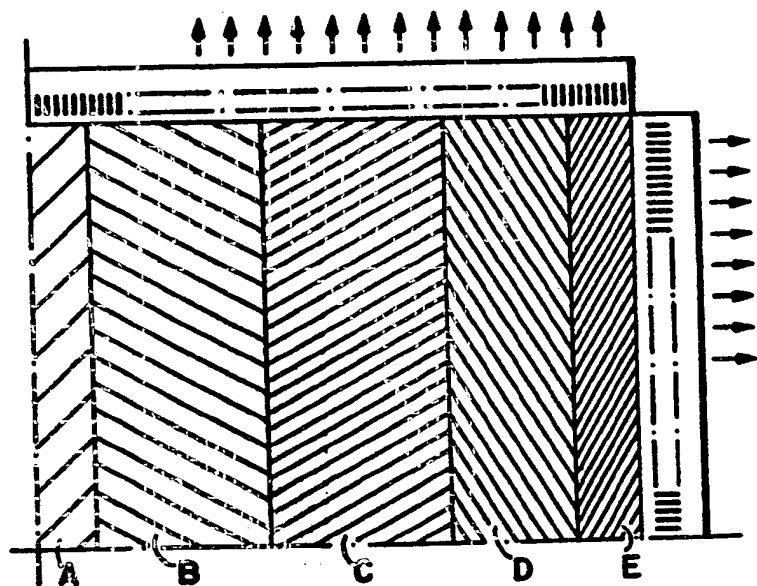


FIG. 7



2-II-PHA 21470



Europäisches Patentamt
European Patent Office
Office européen des brevets



Publication number:

0 372 630 A3

(12)

EUROPEAN PATENT APPLICATION

(21) Application number: 89203034.7

(51) Int. Cl.⁵: H01J 29/07

(22) Date of filing: 29.11.89

(30) Priority: 05.12.88 US 279889

(43) Date of publication of application:
13.06.90 Bulletin 90/24

(84) Designated Contracting States:
DE FR GB IT NL

(89) Date of deferred publication of the search report:
05.06.91 Bulletin 2
91/23

(71) Applicant: N.V. Philips' Gloeilampenfabrieken
Groenewoudseweg 1
NL-5621 BA Eindhoven(NL)

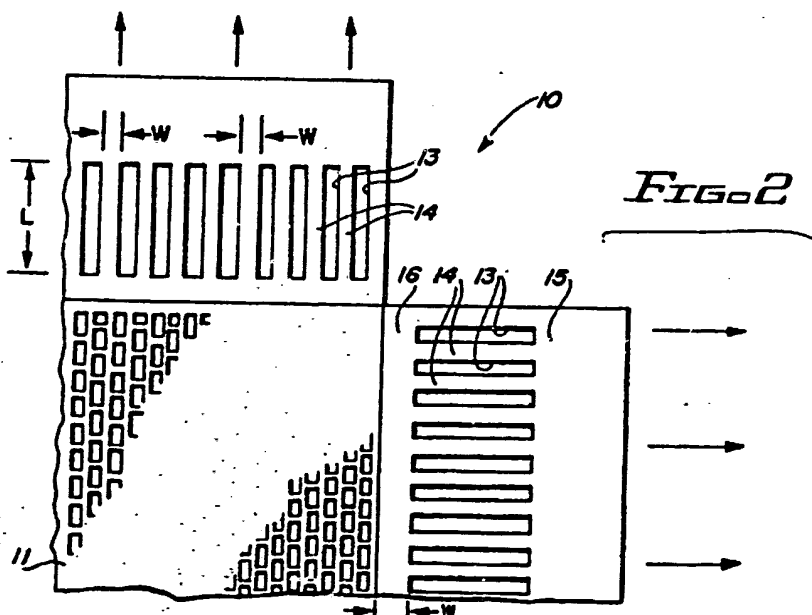
(72) Inventor: Knox, Lawrence
c/o INT. OCTROOIBUREAU B.V. Prof.
Holstlaan 6
NL-5656 AA Eindhoven(NL)

(74) Representative: Koppen, Jan et al
INTERNATIONAAL OCTROOIBUREAU B.V.
Prof. Holstlaan 6
NL-5656 AA Eindhoven(NL)

(54) Shadow mask with border pattern.

(57) A rectangular shadow mask is characterized by having a pattern of slits in the border regions of the mask in order to provide uniform distribution of tensile stresses across the mask when mounted in the

CRT, resulting in improved mechanical and thermal behavior, and enabling the separate fabrication of the mask and display screen of the CRT.



EP 0 372 630 A3



European
Patent Office

EUROPEAN SEARCH REPORT

Application Number

EP 89 20 3034

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
X	FR-A-1 490 705 (COMPAGNIE DE SAINT GOBAIN) * Figure 1; page 1, column 2, line 17 - page 2, column 1, line 7 *	1-6	H 01 J 29/07
A	FR-A-2 366 686 (RCA CORP.) * Figure 18; page 8, lines 6-15 *	1,6	
E	PATENT ABSTRACTS OF JAPAN, vol. 14, no. 252 (E-934)[4195], 30th May 1990; & JP-A-2 72 545 (HITACHI LTD) 12-03-1990	1,2,6	
E	EP-A-0 354 617 (N.V. PHILIPS' GLOEILAMPEN-FABRIEKEN) * Abstract; figure 2; column 5, lines 10-57 *	1,5,6	
			TECHNICAL FIELDS SEARCHED (Int. Cl.5)
			H 01 J
The present search report has been drawn up for all claims			
Place of search		Date of completion of search	Examiner
The Hague		28 February 91	CLARKE N.S.
CATEGORY OF CITED DOCUMENTS X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category A: technological background O: non-written disclosure P: intermediate document T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons &: member of the same patent family, corresponding document			